

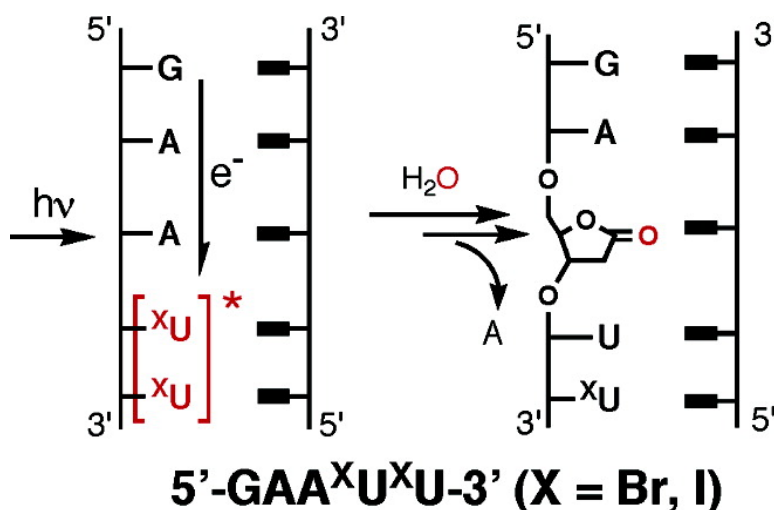
Communication

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Efficient Generation of 2'-Deoxyuridin-5-yl at 5'-(G/C)AA^XU^XU-3' (X = Br, I) Sequences in Duplex DNA under UV Irradiation

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2'-Deoxyuridin-5-yl generated by the photoirradiation of 5-halouracil-containing DNA (d^{Br}U or d^IU) has been used as a probe to reveal the structures of nucleic acids and protein–DNA interactions.^{1–9} Although there have been several reports of sequence specificity in the formation of strand breaks and alkali-labile sites in UV-irradiated d^{Br}U- or d^IU-containing DNA,^{1,10,11} the molecular basis of the sequence-specific photoreactions of 5-halouracil-containing DNA is not well understood. Ito and Rokita recently examined excess electron transfer in DNA using d^{Br}U as an electron acceptor and a tetramethyldiaminonaphthalene donor.¹² Here, we report that 2'-deoxyuridin-5-yl is effectively generated in 5'-(G/C)AA^XU^XU-3' and 5'-(G/C)A^XU^XU-3' (X = Br, I) sequences in double-stranded DNA, which results in the selective formation of a 2'-deoxyribonolactone residue.

We first prepared 450 base pair (bp) DNA fragments containing ^XU by polymerase chain reaction (PCR), in which all thymine residues were substituted with ^{Br}U or ^IU. The DNA fragments were irradiated with monochromatic 302 nm UV light at 0 °C and then analyzed using 6% denaturing polyacrylamide gel electrophoresis (PAGE). The results are shown in Figure 1. Surprisingly, specific cleavage at 5'-(G/C)AA^XU^XU-3' and 5'-(G/C)A^XU^XU-3' sequences in both ^{Br}U- and ^IU-containing DNA fragments was observed in the top and bottom strands, even though slight differences in reactivity were observed in the case of ^{Br}U and ^IU, typically at site 2 and site 9. The same DNA sequence specificity in photoreactivity was observed in a different 450 bp DNA fragment (pET 28a). Importantly, bands reflecting DNA cleavage were observed only after heat treatment, indicating that heat-labile lesions are formed under these conditions (Supporting Information, Figure 1S).

To elucidate the structures of the lesions that caused specific thermal strand cleavage at 5'-(G/C)AA^XU^XU-3' and 5'-(G/C)A^XU^XU-3' sequences, product analysis of photoirradiated 5'-CGAA^IU^IUCG-3'(ODN 1) and 5'-CGAA^{Br}U^{Br}UCG-3'(ODN 2) were investigated in detail. Photoirradiation of ODN 1 for 15 min resulted in the formation of two major products, **1** and **2**, with the concomitant release of free bases, A and ^IU (Figure 2a). Upon heating at 95 °C for 20 min, **1** was degraded to CGAp and pU^IUCG, with the formation of 5-methylene-furanone, indicating that **1** was the ribonolactone-containing octamer, 5'-CGALU^IUCG-3' (L = 2'-deoxyribonolactone).¹³ The structure of **1** was further confirmed by electrospray ionization time-of-flight mass spectrometry (ESI-TOF-MS) analysis (Figure 2S). Using a similar procedure, we found product **2** to be another L-containing octamer, 5'-CGAALUCG-3'. ESI-TOF-MS suggested that peaks a and b are reduced products (Figure 3S). Similarly, photoirradiation of ODN 2 produced L-containing octamers, 5'-CGALU^{Br}UCG-3' (**3**) and

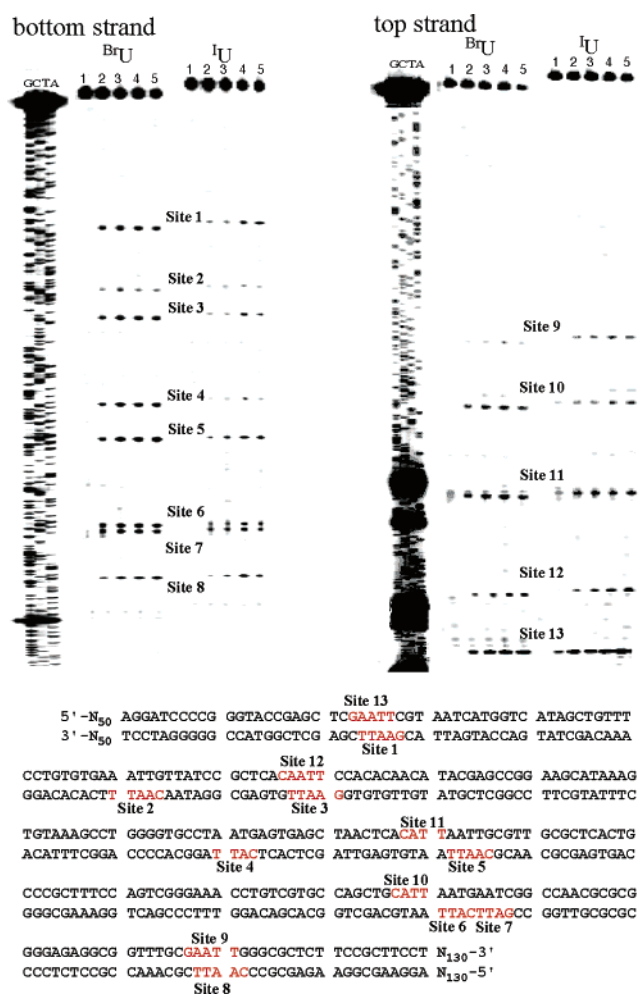


Figure 1. Denaturing polyacrylamide gel electrophoresis (PAGE) of Texas Red-labeled 5-halouracil-substituted 450 bp DNA fragments after photoirradiation. The reaction mixture contained 10 nM DNA fragments and 50 mM sodium cacodylate buffer (pH 7.0). Irradiation was performed using a monochromator (302 nm) at 0 °C. 5'-End-labeled top strand (pUC18 F378-827) and 5'-end-labeled bottom strand (pUC18 R1860-2309) DNA fragments were used. Lanes 1–5: DNA fragments (10 nM) were irradiated for 0, 15, 30, 45, and 60 s for ^{Br}U and 0, 45, 90, 135, and 180 s for ^IU (left, ^{Br}U-containing DNA fragments; right, ^IU-containing DNA fragments). Sequences containing cleavage sites are shown in red. All Ts were substituted with either ^{Br}U or ^IU.

5'-CGAALUCG-3' (**2**), as the major products, with the concomitant release of A and ^{Br}U.

Peaks c–e are assumed to be the photodimer, the 2'-hydroxylated product, and the reduced product, respectively (Figures 2b and 3S). Quantitative product analysis of photoirradiated ODNs 1 and 2 clearly indicates that the amount of free bases corresponds well to the amount of L-containing octamers **1**–**3** (Table 1).

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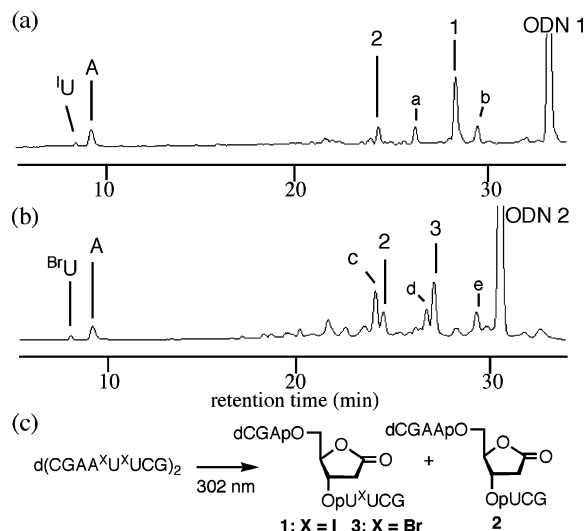


Figure 2. HPLC analysis of UV-irradiated 5'-CGAA^IU^IUCG-3' (ODN 1) (a) and 5'-CGAA^{Br}U^{Br}UCG-3' (ODN 2) (b). Photoproducts (1–3) from ODN 1 and ODN 2 (c). The reaction mixture (total volume 10 μ L) contained 10 μ M (strand concentration) DNA oligomers and 20 mM NaCl in 50 mM sodium cacodylate buffer (pH 7.0). Irradiation was performed with a monochromator (302 nm) at 0 $^{\circ}$ C. The reaction mixtures (10 μ L) were analyzed by HPLC on Wako 5-ODS-H columns (4.6 \times 150 mm). Elution was performed with 50 mM ammonium formate (pH 6.5) containing 0–12% acetonitrile over a linear gradient for 40 min at a flow rate of 1.0 mL/min at 40 $^{\circ}$ C.

Table 1. Product Analysis of the Photoreaction of ODN 1 and 2^a

	conversion (%)	L-containing octamer yield, %			free base, μ M (%)		
		1	2	3	A	^I U	^{Br} U
ODN 1	26	9	5		1.0 (10)	0.5 (5)	
ODN 2	30		5	13	1.4 (14)		0.5 (5)

^a Yields were determined by HPLC. Numbers in parentheses are % yield of free bases, based on the strand concentrations of ODNs.

When ODNs 1 or 2 were irradiated (302 nm) in H₂¹⁸O, incorporation of ¹⁸O atoms from H₂¹⁸O into 1 and 3 was observed in both cases, indicating that H₂O is the source of the carbonyl oxygen of ribonolactone (Figure 2S). From these observations, we proposed that a possible mechanism for the efficient photoreactions at 5'-GAA^XU^XU-3' sequences produces 1–3 (Scheme 1S). The initial electron transfer would occur from G to the electron-deficient, stacked ^XU^XU to provide the anion radical. Release of the halogen anion from ^XU^XU generates 2'-deoxyuridin-5-yl to abstract the C1' hydrogen from the adjacent 5' dA or d^XU. Electron transfer from the C1' radical of dA or d^XU to the guanine cation radical gives rise to a C1' cation and regeneration of guanine. Furthermore, G on the complementary strand (G/C to C/G base pair) also results in efficient electron transfer, inducing strand cleavage. Large interstrand stacking of G and A is assumed to contribute to the electron transfer from G to A. To examine the molecular basis of the efficient photoreaction, the photoreactivities of various oligonucleotides were investigated, and the results are summarized in Table 2. Since a change from ^{Br}U^{Br}U to ^{Br}UT (ODN 3) caused the photoreactivity to be substantially retained, and a single ribonolactone was formed (Figure 4S), further investigation was conducted using the ^{Br}UT sequence. The intervening A between G and ^XU^XU is considered to act as a bridge between the donor and acceptor, which may prevent rapid back electron transfer.¹⁴ In fact, the number of intervening As strongly affects the yield of the L-containing oligomer. The G^{Br}UT-containing strands (ODN 4/5) did not show the reactivity, and single-A-containing strands (ODN

Table 2. Product Analysis of the Photoreaction Using ODN 3–13^a

ODN	conversion (%)	L-containing oligomer (%)
5'-CGAA ^{Br} UTCG-3' (ODN 3)	21	17
3'-GCT ^{Br} UAAGC-5'		
5'-CTG ^{Br} UTATC-3' (ODN 4)	<1	<1
3'-GAC AATAG-5' (ODN 5)		
5'-CTGA ^{Br} UTATC-3' (ODN 6)	15	4
3'-GACT AATAG-5' (ODN 7)		
5'-CTGAA ^{Br} UTATC-3' (ODN 8)	39	11
3'-GACTT AATAG-5' (ODN 9)		
5'-CTGAAA ^{Br} UTATC-3' (ODN 10)	28	5
3'-GACTTT AATAG-5' (ODN 11)		
5'-CTGAA ^{Br} UTATC-3' (ODN 8)	<1	<1
5'-CGAA ^{Br} UGATC-3' (ODN 12)		
3'-GCTT ACTAG-5' (ODN 13)	<1	<1

^a Reaction mixture (total volume 10 μ L) contained 10 μ M (strand concentration) of DNA oligomers and 20 mM NaCl in 50 mM sodium cacodylate buffer (pH 7.0). Irradiation was performed with a monochromator (302 nm) at 0 $^{\circ}$ C for 5 min (ODN 3 and 4) or 10 min (ODN 5–14). The reaction mixtures (10 μ L) were analyzed by HPLC.

6/7) show lower photoreactivity than GAA^{Br}UT. This is probably due to the faster back electron transfer relative to the elimination of bromo anion. Also, the fact that the reactivity of GAAA^{Br}UT (ODN 10/11) is lower than that of GAA^{Br}UT indicates that intervening three As slightly weaken the efficiency of electron transfer from G. AA is the most suitable bridge for the charge separation after electron transfer from G to ^{Br}U (ODN 8/9). Furthermore, neither the single-strand (ODN 8) nor single ^{Br}U (ODN 12/13) produced L-containing oligomer. These results indicate that ^{Br}U^{Br}U or ^{Br}UT residues separated by an A bridge from an electron-donating G on the 5' side in a duplex structure are essential for efficient ribonolactone formation.

In conclusion, we have identified two hot spot sequences, 5'-(G/C)AA^XU^XU-3' and 5'-(G/C)A^XU^XU-3', in 5-halouracil-containing DNA that induce damage to DNA under UV irradiation. These observations will be useful in studying the molecular basis of sequence dependence in the DNA-damaging process in UV-irradiated 5-halouracil-containing DNA.

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Supporting Information Available: PAGE analysis of a different 450 bp fragments (Figure 1S), product analysis of 1–3 (Figure 2S), peaks a–e (Figure 3S), and photoradiated ODN 3 (Figure 4S), and the proposed mechanism of the photoreaction (Scheme 1S) (PDF). This material is available free of charge via the Internet at <http://pubs.acs.org>.

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